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Transport properties of IMD-processed 100 m class 6-filament MgB_2 wire and solenoid coil

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Outline

1. Introduction of internal Mg diffusion (IMD) processed MgB_2 wires
2. C-doped IMD-processed wires with crystalline boron powders
 - Purity of crystalline boron powders
 - Wire diameter
3. 100 m multifilament IMD-processed MgB_2 wires
 - Filament configuration
 - Wire diameter
 - n values
 - Uniformity of transport properties
4. IMD-processed MgB_2 solenoid coils
 - Specifications of solenoid coils
 - Superconducting properties
5. Summary

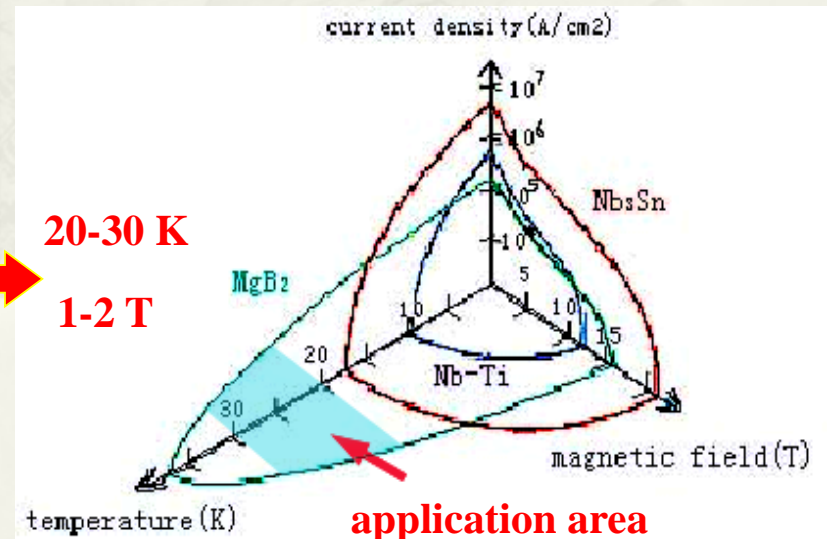
Superconductor-MgB₂

Superconducting Specifications of Practical superconductors

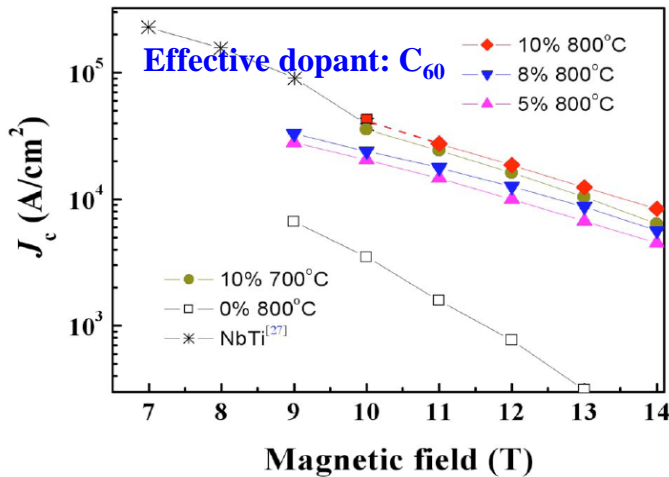
Material	T_c (K)	Anisotropy	B_{c2} at 4.2 K (T)	Coherence length ξ (0) (nm)	Penetration depth λ (0) (nm)
NbTi	9	Negligible	11-12	4-5	240
Nb ₃ Sn	18	Negligible	25-29	3	65
MgB₂	39	1.5-5	>30	10	50-100
Bi2223	110	50-200	>100	1.5	150
YBCO	93	5-7	>100	1.5	150
IBS-122	38	1-2	>100 (0K)	3	200

Advantages of MgB₂

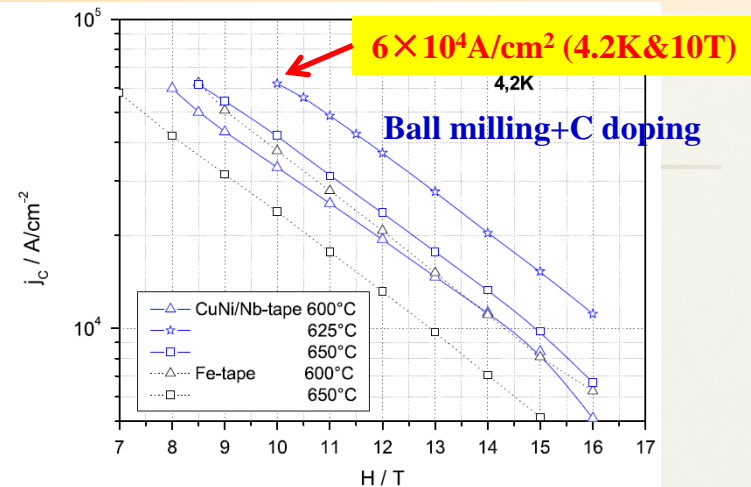
- Highest T_c (~40K) among metallic superconductors
- No grain orientation required (Easy to fabricate long tape or wire)
- Low materials cost
- Good mechanical properties
- Light weight material



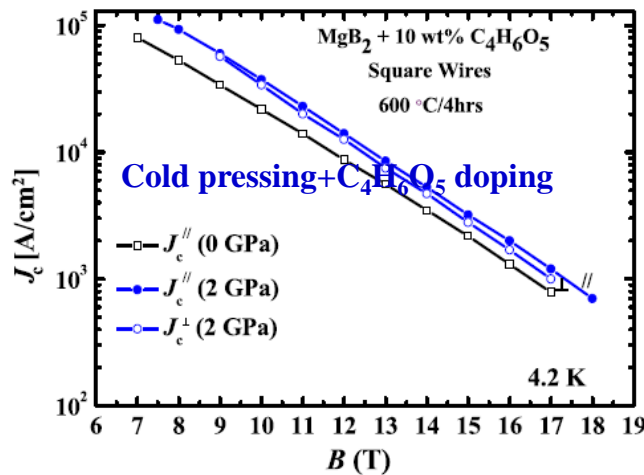
Transport properties of PIT wires or tapes (1G)



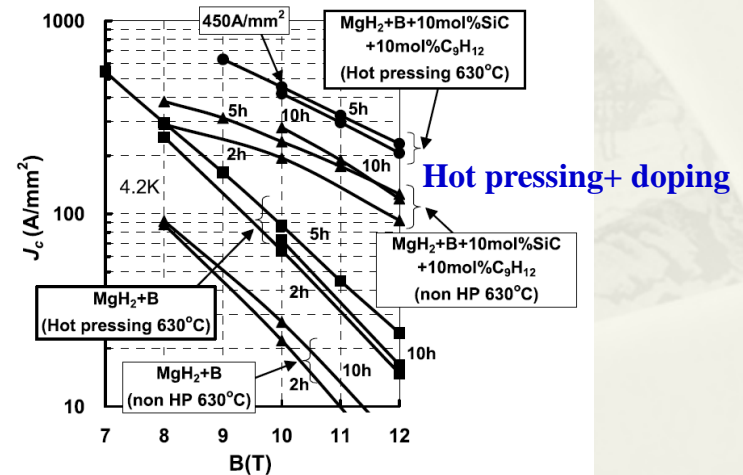
X.P. Zhang, *JAP.*, 103 (2008) 103915



W. Hassler, *SUST.*, 21 (2008) 062001



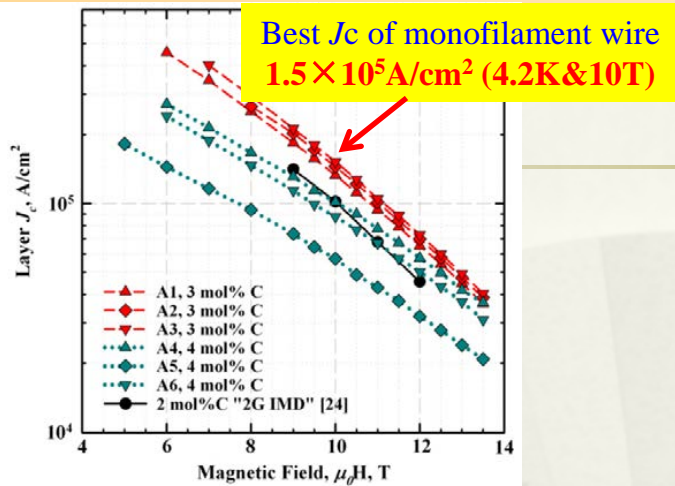
M. S. A. Hossain, *SUST.*, 22 (2009) 095204



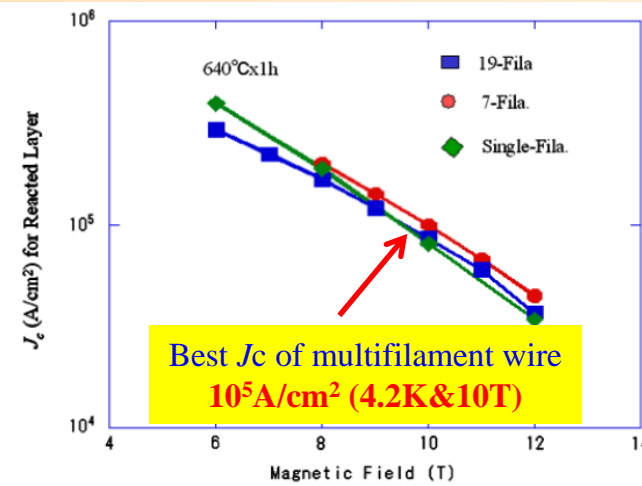
H. Yamada, *SUST.*, 23 (2010) 045030

Grain connectivity problem?

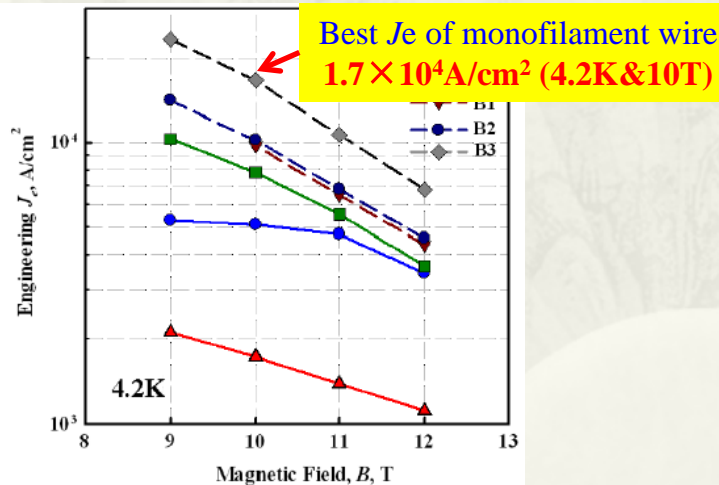
Jc properties of IMD (or AIMI) wires (2G)



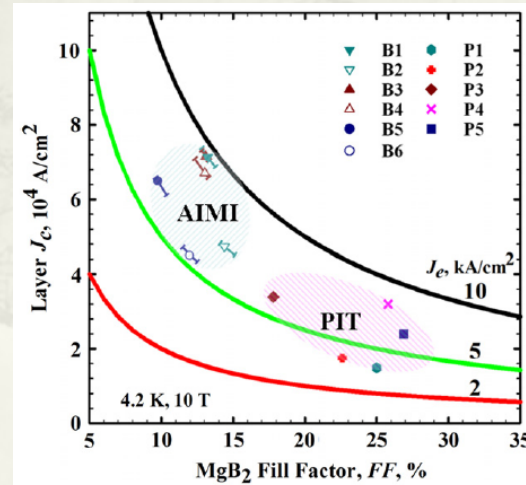
G.Z. Li, *SUST.* 26 (2013) 095007



K. Togano, *SUST.* 23 (2010) 085002



G.Z. Li, *SUST.* 25 (2012) 115023



G.Z. Li, *SUST.* 26 (2013) 095007

Good grain connectivity!

IMD-processed wires with crystalline B

Motivation

The high J_c has been developed using **amorphous** nano B powders by *NIMS* and *OSU-HTR*.

Amorphous nano B: **expensive and hard to get!**

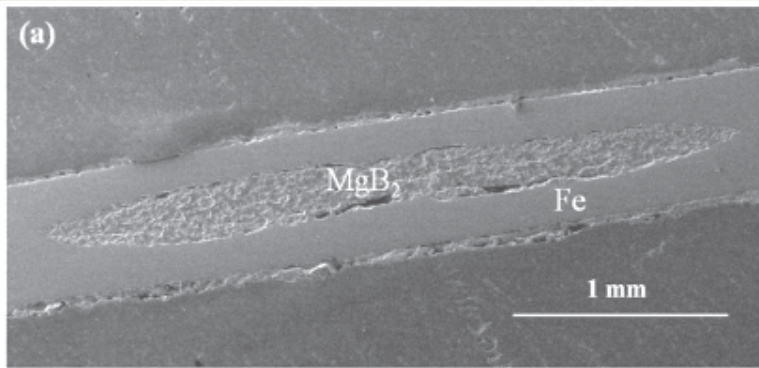
What about the **cheap crystalline** boron powders: 96% and 99.999% (5NB)?

Table 1. The specifications of all MgB₂ samples.

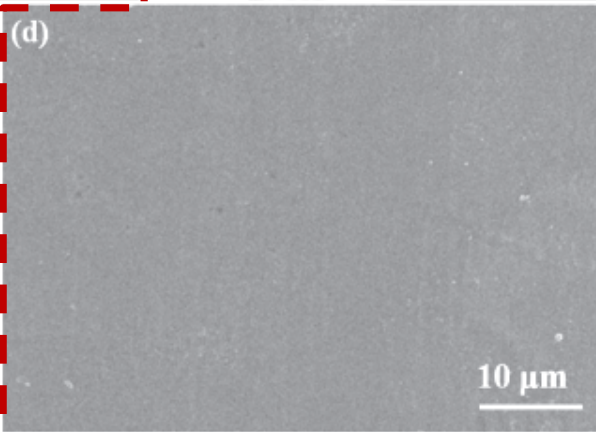
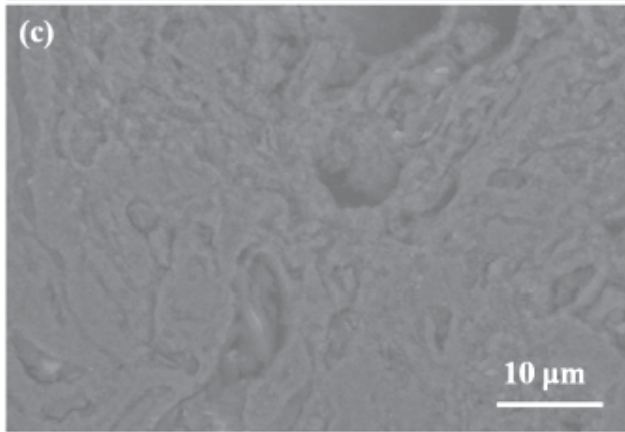
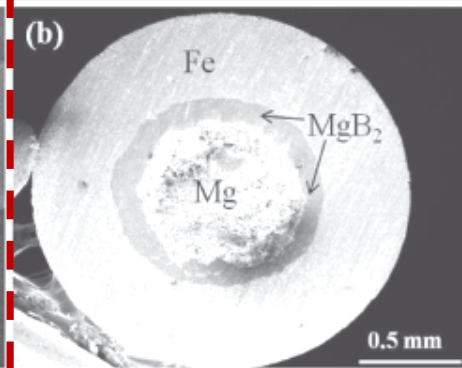
No.	Name	Boron	Process	Doped C (at.%)	Size (mm)	Reaction temperature (°C)	Reaction time (h)	I_c at 4.2 K & 10 T (A)
1	P1	96B	PIT	8	0.55 * 3.8	800	1	4.4
2	I1	96B	IMD	8	1.75	650	5	31
3	I2	96B	IMD	8	1.75	700	1	28
4	I3	96B	IMD	8	1.75	800	1	11.2
5	P2	5NB	PIT	8	0.55 * 3.8	850	1	113
6	I4	5NB	IMD	8	1.75	650	5	108
7	I5	5NB	IMD	8	1.75	700	1	96
8	I6	5NB	IMD	8	1.75	800	1	—
9	I7	5NB	IMD	8	1.105	650	3	38.4
10	I8	5NB	IMD	8	1.105	650	5	52.2
11	I9	5NB	IMD	8	1.105	700	1	57.6
12	I10	5NB	IMD	8	0.63	650	3	16.2
13	I11	5NB	IMD	8	0.63	650	5	16.8
14	I12	5NB	IMD	8	0.63	700	1	13.8

IMD wire: denser MgB_2 layer

PIT tape



IMD wire



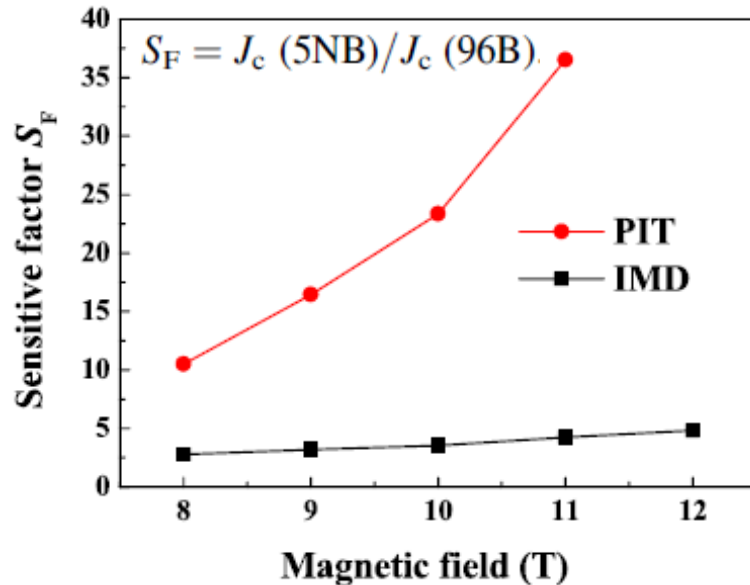
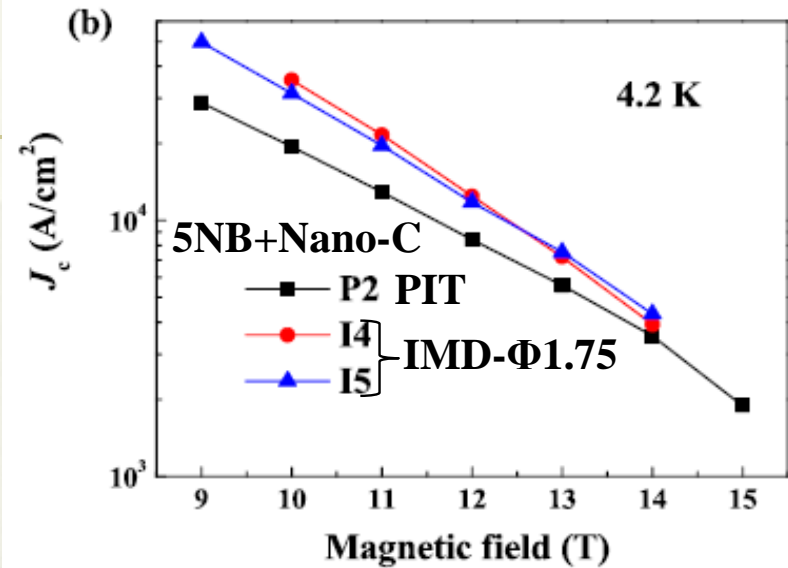
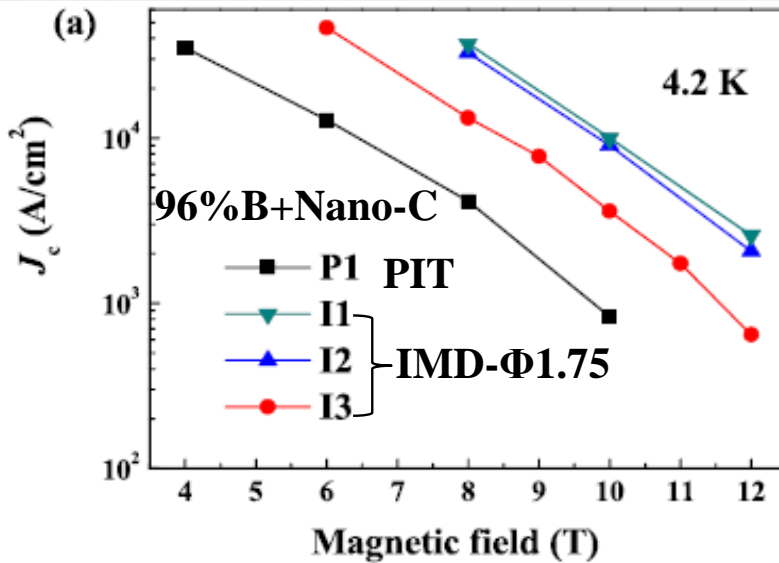
holes, cracks

HV: 252

dense

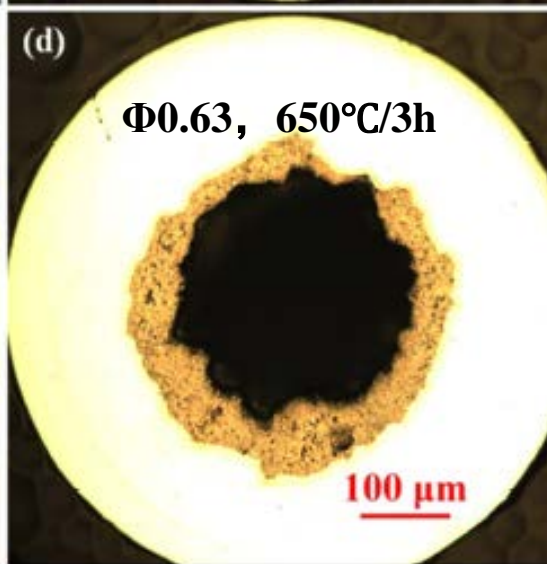
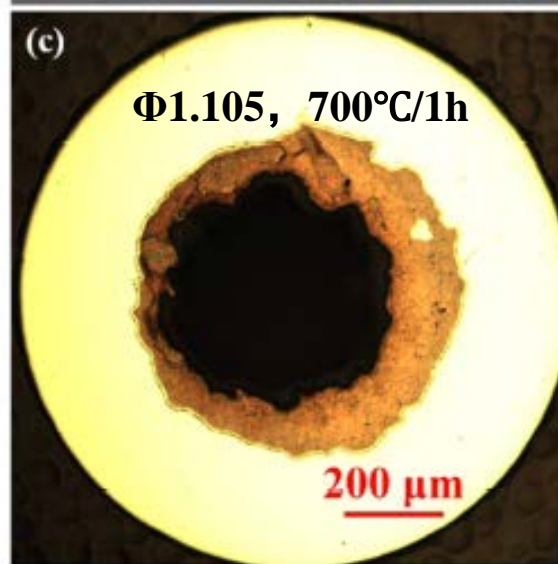
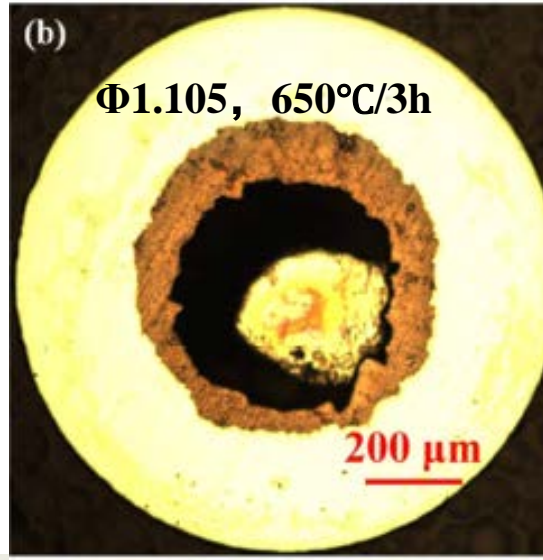
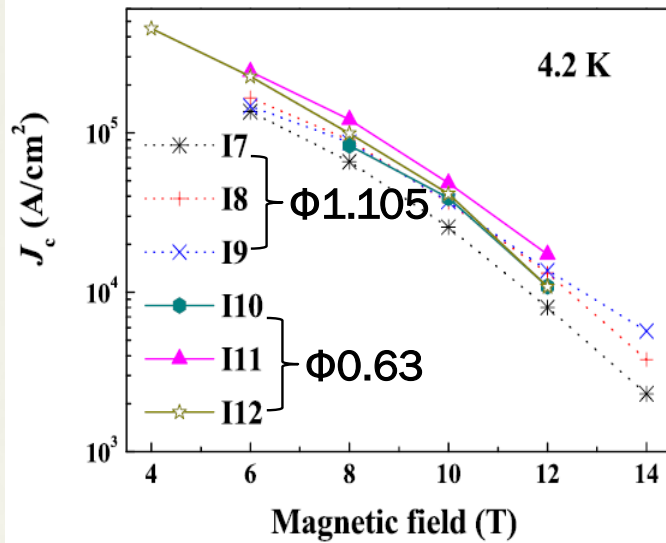
HV: 630

IMD wire: larger J_c values



- J_c - B properties of IMD wires are improved by using two kinds of boron powders, compared to PIT tapes.
- The transport J_c values of the MgB_2 samples fabricated by the IMD method are less sensitive to the purity of the boron powder, compared with those fabricated by the PIT method.

Smaller diameter, higher J_c values



Small diameter



Thin B layer



Fully reacted MgB_2

Problem: B-rich particles

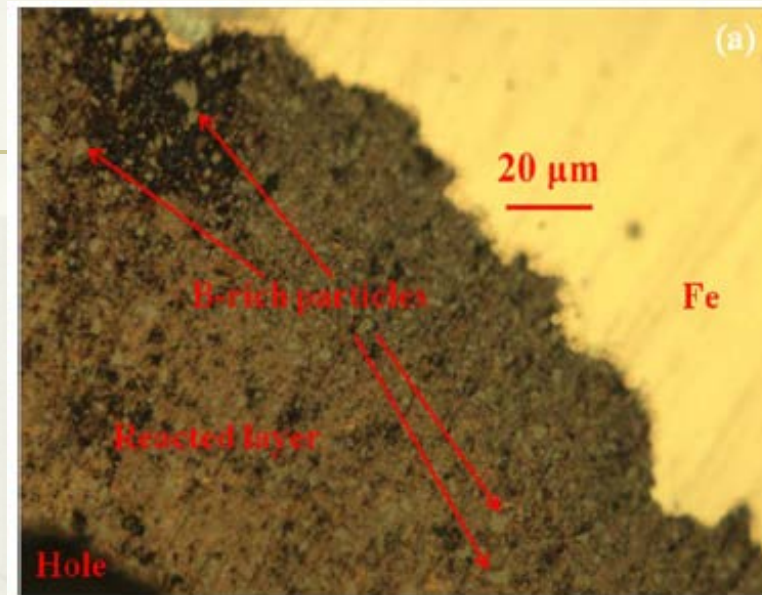
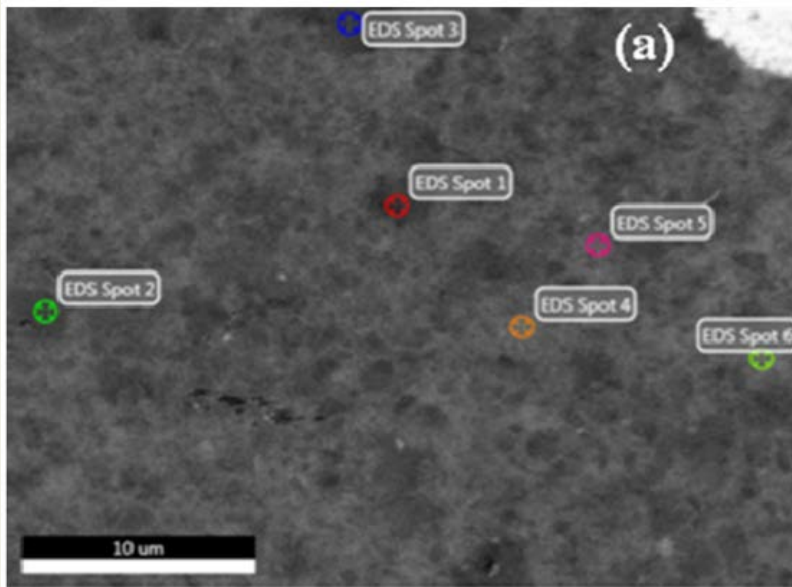


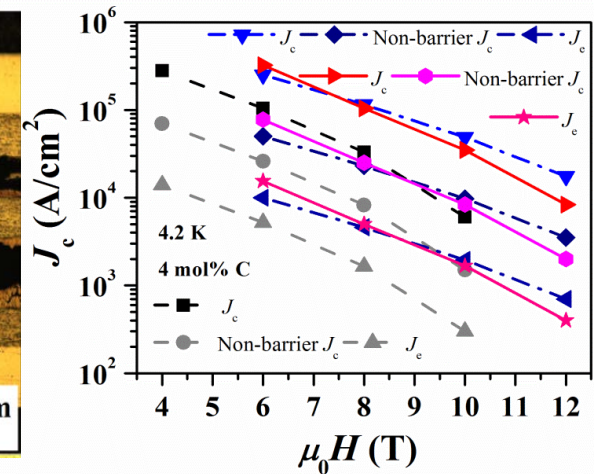
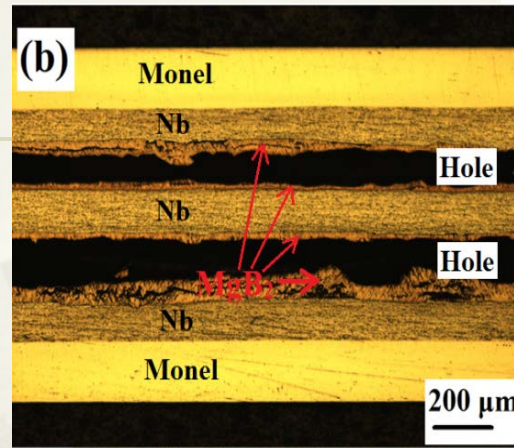
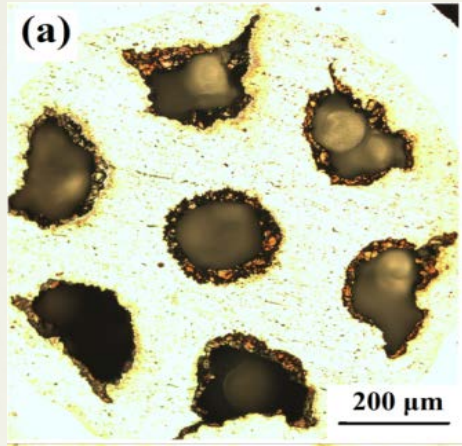
Table 2. The results of the elemental analysis of sample I8.

Element (at.%)	Spot 1	Spot 2	Spot 3	Spot 4	Spot 5	Spot 6
B K	82.11	85.27	85.65	15.03	60.63	74.06
C K	7.67	6.77	7.13	20.16	11.3	7.89
O K	2.13	1.39	0.59	25.98	8.57	3.61
Mg K	7.92	6.53	6.6	35.4	19.11	14.32
Fe L	0.17	0.04	0.03	3.43	0.39	0.12

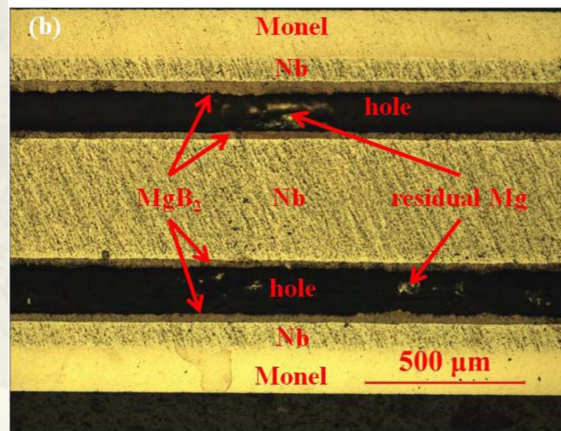
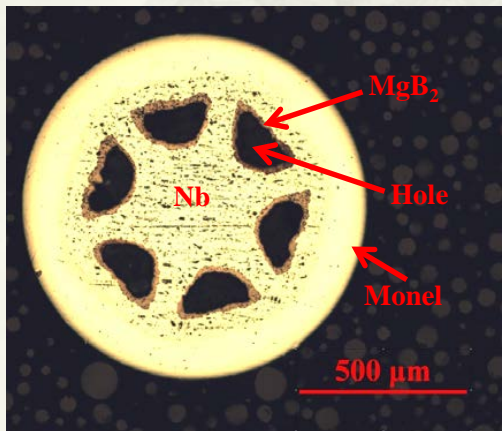
➤ Plenty of B-rich particles in the MgB₂ layer is due to the large size B powders (**several μm**).

➤ The *J_c* of IMD wire will be **further improved** by using the **nano-sized B powders**.

Filament configuration

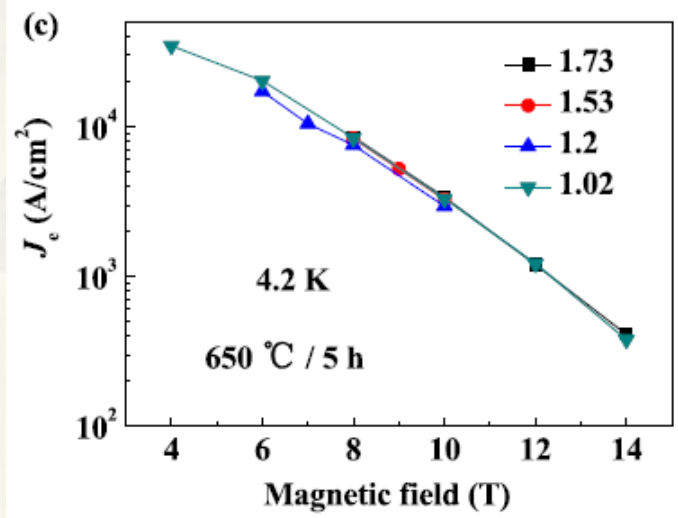
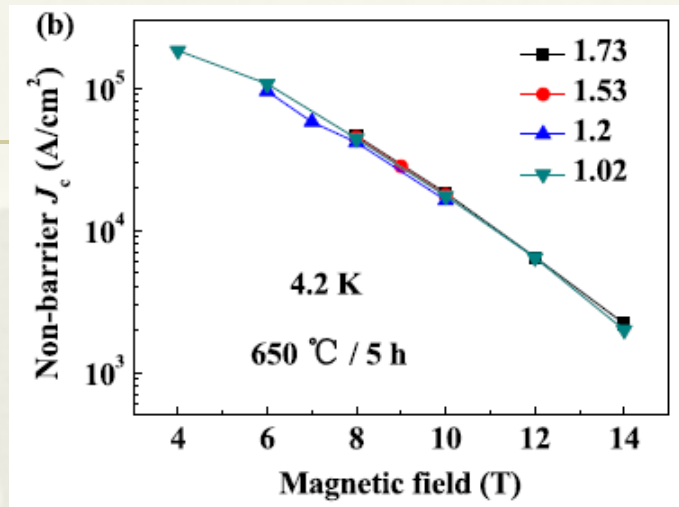
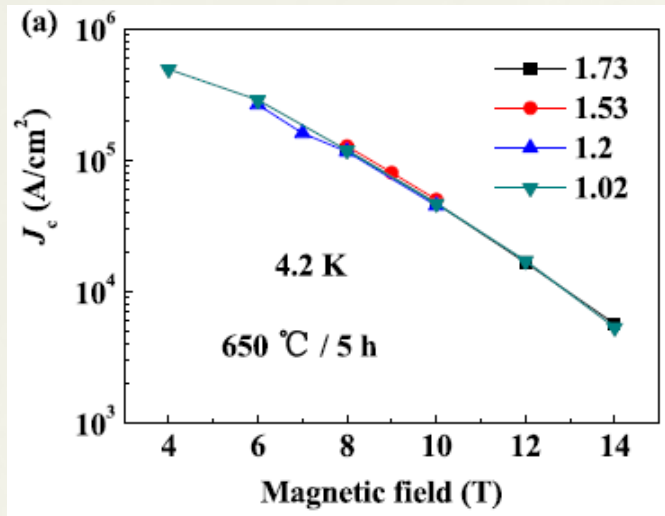


7-filament wire: longitudinal homogeneity is not good



6-filament wire: good uniformity for 100 m wire

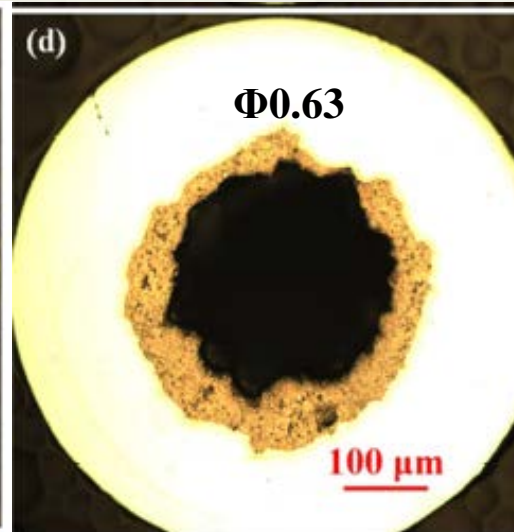
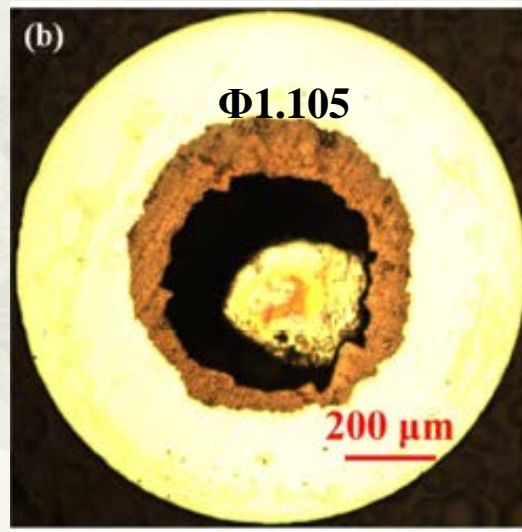
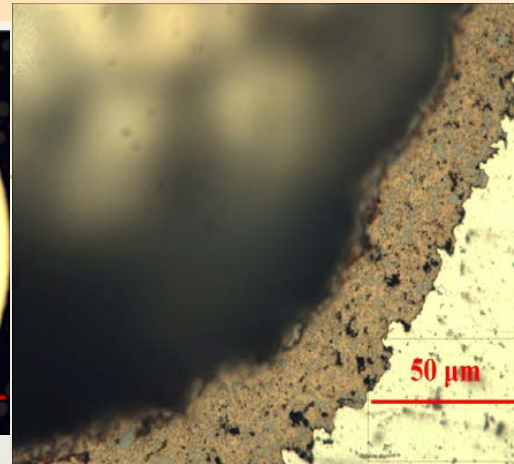
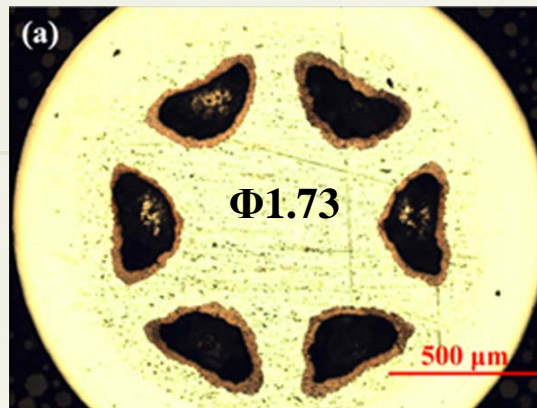
Transport properties of 100 m 6-filamentary wire



Fill factor: 6.5%

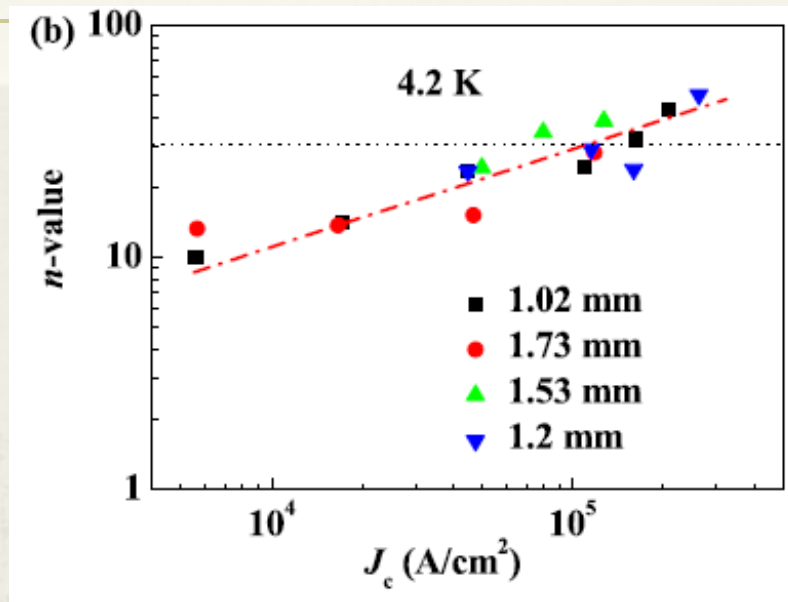
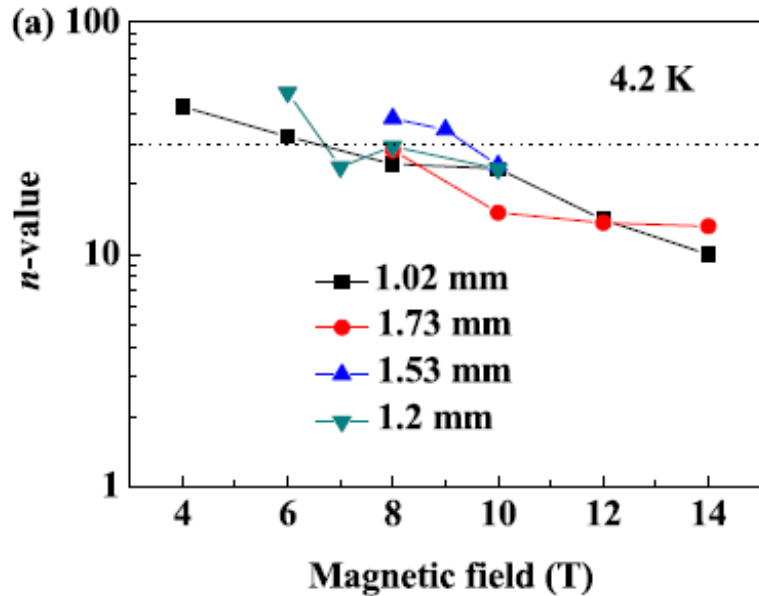
- The J_c of 100 m 6-filamentary IMD wire with 1.02 mm diameter was 4.6×10^4 A/cm^2 at 4.2 K and 10 T.
- The $J_c(J_e)$ values of 6-filament IMD wire with different diameter were almost same.

Thin B layer for multifilament wire



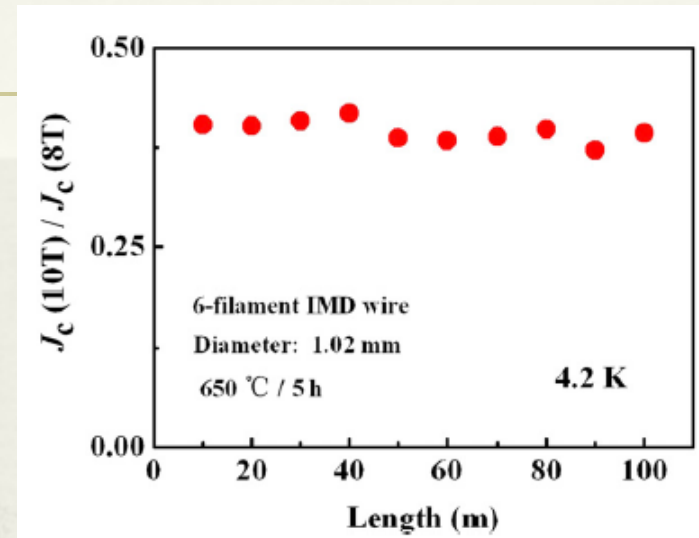
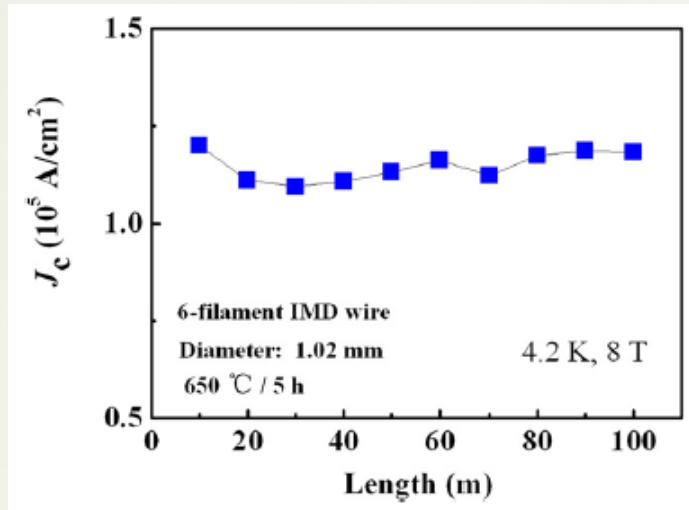
➤ The thin B layer for multifilament wire is benefit for the full reaction between Mg and B, compared to the monofilament wire.

high n values



- The n values of IMD wires are **around 30** at 4.2 K and 8 T.
- Larger J_c led to a higher n value.

Uniformity of transport properties



D.L. Wang, *SUST.* 29 (2016) 065003

- The ratio of the standard deviation to the average value is **3.3%**, suggesting that the J_c values have a **fairly uniform distribution throughout the long wire**.
- The lowest J_c value is 1.09×10^5 A cm⁻² at 4.2 K and 8 T, which is close to the average value (1.15×10^5 A cm⁻²), indicating that **there were no serious defects along the length of the wire**.

Longitudinal homogeneity evaluation



Direct

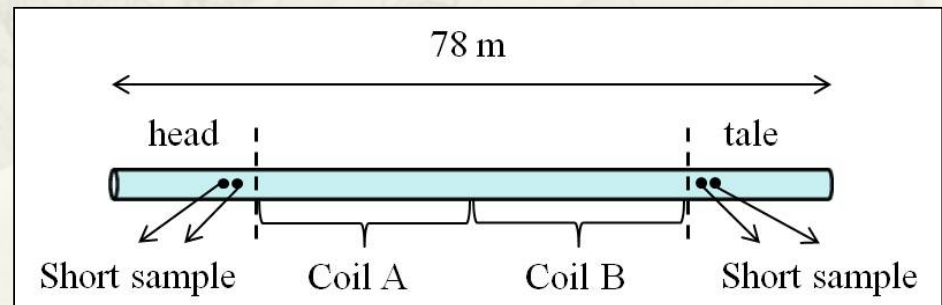
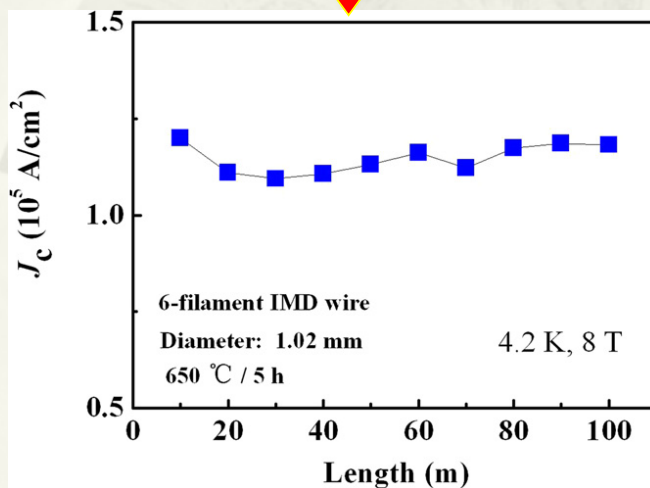


Challenge

- The lowest J_c value determined the J_c value of the whole wire.
- To wind wire into a coil without significant loss of J_c .

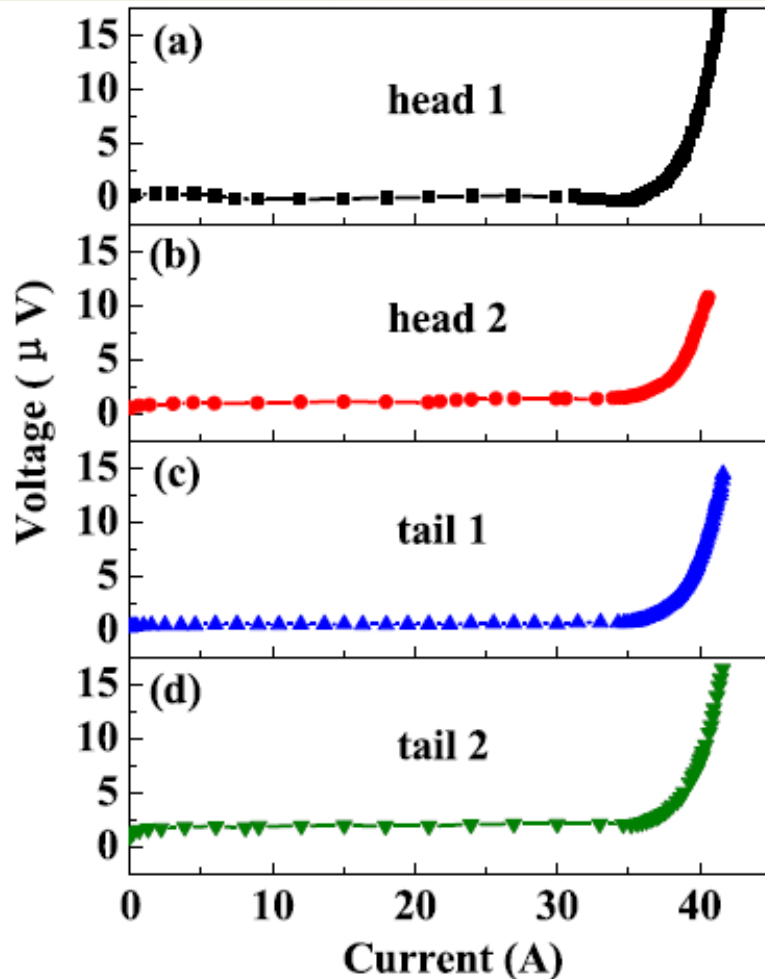


Indirect



Short samples: I_c and n values

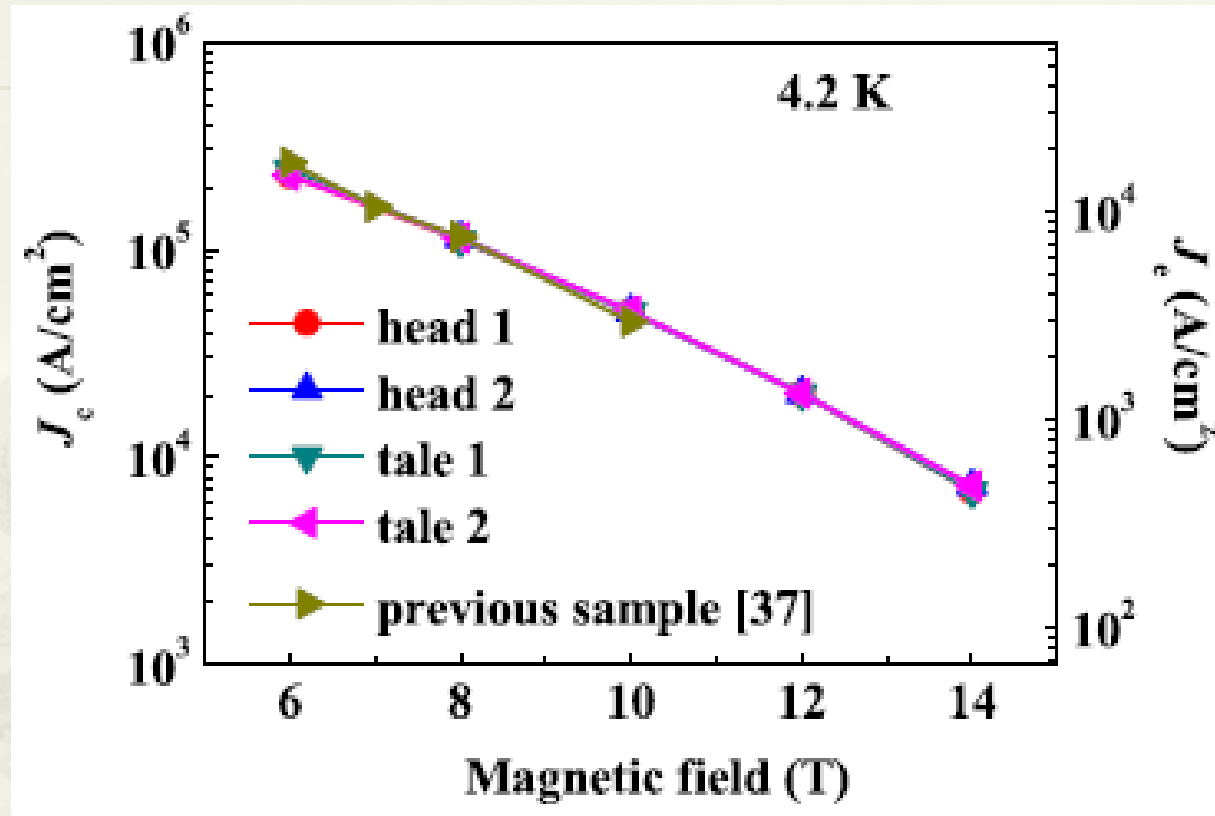
Fitting parameters of I - V curves for short samples at 10 T



Sample	I_c (A)	n -value
head 1	37	21.5
head 2	37.2	22.6
tail 1	37.2	21
tail 2	37.4	23.1
Average	37.2	22.1

➤ Both I_{cs} and n -values of four short IMD wires are close to each other, indicating that the long six-filament IMD-processed MgB_2 wire is uniform from head to tail.

Short samples: J_c at 4.2 K



➤ The J_c s of four short IMD wires are **close to each other** and our **previous 100 m IMD wires** at 4.2 K.

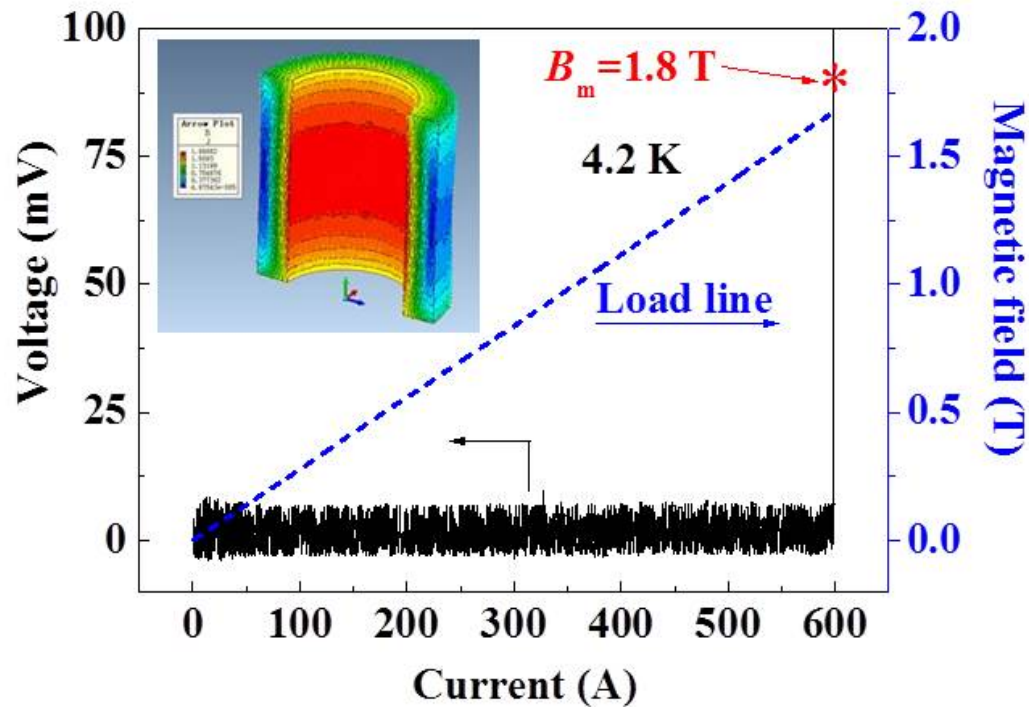
MgB₂ solenoid coils

Specifications	Coil A	Coil B
Wire structure	MgB ₂ /(Nb/ /Monel)	MgB ₂ /(Nb/ Monel)
Number of filaments	6	6
Wire diameter (mm)	1.2	1.2
Winding inner diameter (mm)	38	38
Winding outer diameter (mm)	57.6	57.8
Winding height (mm)	60	60
Number of turns	178	174
Wire length (m)	26.7	26.1



Coil

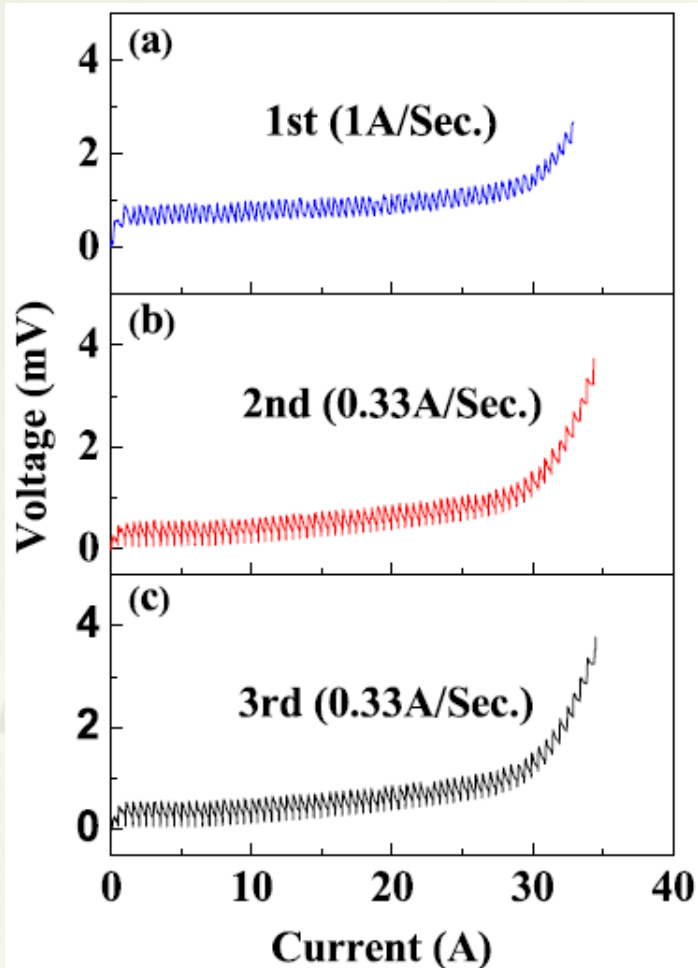
Transport properties of Coil A



- The transport current of Coil A reached **599 A at 4.2 K**.
- Coil A generated a **self-field of 1.67 T** at the coil center.

Transport properties of Coil B

Three time excitation at 4.2 K and 10 T

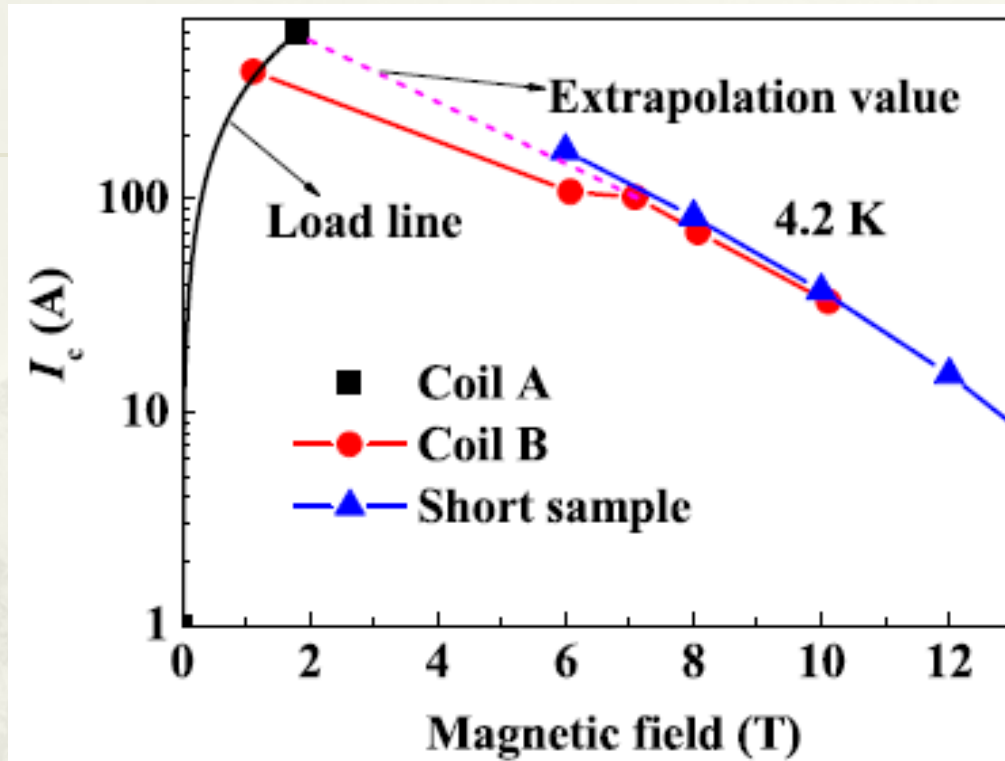


Fitting parameters of I - V curves for
Coil B at 4.2 K and 10 T

No.	I_c (A)	n -value
1st	32.8	14.9
2nd	33	12.9
3rd	33.4	13.3
Average	33.1	13.7

- No training effect.
- I_c (33.1 A) of Coil B is close to I_c (37.2 A) of short samples.

Transport properties of Coil A and B



➤ Above 7 T, the I - B curve of Coil B was straight and in good agreement with that of the short sample.

➤ Both the magnetic fields generated by two coils (H^{gen}) coincide with the same formula: $H^{\text{gen}} = (28 \text{ Gs A}^{-1}) I_c$

Summary

1. The high J_c of IMD wire is also achieved by using the crystalline boron powders. The best J_c value of IMD wire is 6.2×10^4 A/cm² at 4.2 K & 10 T. **The J_c can be further improved by decreasing the size of crystalline B powders.**
2. We successfully fabricated a 100 m-level, Nb-reinforced, 6-filament MgB₂ wire by an IMD process. **The highly uniform microstructure and transport performance are obtained for 100m long six-filament MgB₂ wire.**
3. **Two solenoid coils were made by a wind-and-react method using long wires.** One coil exhibited J_c of 4.5×10^4 A cm⁻² at 10 T and 4.2 K, which is similar to the short samples. Another coil generated a **central field of 1.67 T and a maximum magnetic field of 1.8 T at zero external field.**

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Thank you for your attention!